ODISCUSSION ON Defects and Materials



- Notes from last Meeting in June
 - Mobility values, discrepancies, in low and high fields
 - EPR studies
 - Modeling of V-I in clusters
 - Acceptor removal in p type silicon
 - Donor removal in n-type Si
 - Defect characterization (Wodean on p type)
 - Data base on defects
 - N-enriched project
- Input from Ioana
 - Bucharest starting to model the defects that are doing the leakage current
 - Results on EPR attached to the agenda
- Question from Elena
 - Should we introduce a new way of labelling of our defects?
- Remark from Juozas on interpretation of TSC data with different filling
 - How to deal with this?